Gas Filter

Ultra-high purity in-line







IGS Gas Filter

Gasket Filter









ELEMENT SELECTION GUIDE

No.	GAS CHEMICAL FORMULA	EL	ELEMENT MATERIAL			
140.	GAS CHEMICAL I GRINGLA		SUS316L	HC-276	PTFE	
1	Argon	Ar	•	•	•	
2	Arsine	AsH3	•	х	•	
3	Boron Trichloride	BCl3	•	•	•	
4	Boron Trifluoride	BF3	x	•	•	
5	Diborane	B2H6	•	•	•	
6	Carbon Dioxide	CO2	•	•	•	
7	Carbon Monoxide	СО	•	•	•	
8	Chlorine	Cl2	•	•	•	
9	Halocarbon 13	CCIF3	•	•	•	
10	Halocarbon 14 Tetrafluoromethane	CF4	•	•	•	
11	Halocarbon 23 Trifluoromethane	CHF3	•	•	•	
12	Halocarbon 115	C2CIF5	•	•	•	
13	Halocarbon 116 Hexafluoroethane	C2F6	•	•	•	
14	Halocarbon 23 Trifluoromethane	CH3F	•	•	•	
15	Halocarbon 318 Octafluorocyclobutane	C4F8	•	•	•	
16	Halocarbon 218 Perfluoropropane	C3F8	•	•	•	
17	Trimethylamine	(CH3)3N	•	•	•	
18	Germane	GeH4	•	•	•	
19	Helium	He	•	•	•	
20	Hydrogen	H2	•	•	•	
21	Hydrogen Bromide	HBr	х	•	•	
22	Hydrogen Chloride	HCI	х	•	•	
23	Hydrogen Fluoride	HF	х	•	•	
24	Hydrogen Selenide	H2Se	•	•	•	
25	Hydrogen Sulfide	H2S	•	•	•	
26	Krypton	Kr	•	•	•	
27	Ammonia	NH3	•	•	•	
28	Neon	Ne	•	•	•	
29	Nitrogen	N2	•	•	•	
30	Nitrogen Trifuoride	NF3	•	•	•	
31	Nitrous Oxide	N2O	•	•	•	
32	Oxygen	02	•	•	•	
33	Ozone	O3	Х	х	•	
34	Phosphine	PH3	•	•	•	
35	Phosphorous Trifluoride	PF3	Х	•	•	
36	Silane	SiH4	•	•	•	
37	Silicon Tetrachloride	SiCl4	х	•	•	
38	Silicon Tetrafluoride	SiF4	х	•	•	
39	Dichlorosilane	SiH2Cl2	х	•	•	
40	Halocarbon 116 Hexafluoroethane	SF6	•	•	•	
41	Trichlorosilane	SiHCl3	•	•	•	
42	Trimethylsilane	SiH(CH3)3	•	•	•	
43	Tungsten Hexafluoride	WF6	х	•	•	
44	Xenon	Xe	•	•	•	

^{• -} Recommended, ▲- Limited, X - Not Recommended

SPECIFICATION

ltem	Sample Q'ty	METHOD	CRITERIA
Raw Material & Element Powder	5PC/Lot*1)	(1) Mill Certificate(2) Visual(3) Dimension : Vernier CaliperTape measure	 Confirm chemical contents and Mechanical properties in mill certificate. No harmful damage on surface. Meet to specification for O.D. and length. Confirm Powder certificate.
Element	5PC/Lot	(1)Visual (2)Dimension: Vernier Caliper	- No harmful damage on surface. - Meet to specification for O.D. and length.
Visual	100%	External: Visual Inspection	- No burr, rust, discoloration, mechanical damage, and contamination
Dimensional Inspection	KS A ISO 2859	(1)O.D.: Vernier Caliper (2)Length: Vernier Caliper	Designated dimension shall be met to required specification
Inner Surface Roughness	1PC / LOT*3)	(1)Cut Off Length : 0.25mm (2)Measuring Length: 1.25mm	- Ra ≤5 μinch
Welding	100%	External: Visual, Magnifier	- Maintain even width and height for welding bead - No Pit or crack is allowed - No discoloration
Particle	100%	(1)Test Fluid: Dry Air (2)Pressure: 4 ~ 6 kgf/cm² (3)Flow rate: 35 ~ 40ℓ/min (4)Test time: 1min	- No count 0.0025µinch and larger
He Leak	100%	Equipment: He Leak Detector	- 1 x 10 ⁻⁹ atm·cc/sec

Note: *1) Inspection Lot: Each heat number

*2) AQL 2.5, II ,1time sampling, normal inspection *3) Inspection Lot: Each Traveller

SELECTION CRITERIA

1	Particle Retention Efficiency
2	Particle Shedding
3	Removal Rating
4	Pressure Drop & Inlet Pressure
5	Flow Rate
6	Max. Operating Temperature
7	Gas Compatibility & Resistance
8	Connection Type
8	Pollutants & Contaminants
10	Cleanliness

TKF Ultra-high purity in-line Gas Filter

PRODUCTION FLOW

CAREFULLY SELECTED MATERIALS

Selecting and standardizing a highly clean material reduced non-metalic inclusions and outgases. Further, production of VAR material that is highly resistant to corrosion and Hastelloy[®] C-22[™] material are even made possible.

HIGH PRECISION MACHINING PROCESS

Using fully automatic, high precision, high-speed CNC Machining center and lathe, a precision machining process is established.

With high precision locating, automatic dimensional calculation and automatic compensation, an unattended, labor-reduced production process is made possible.

ULTRA-HIGH CLEANING PROCESS

Using TKF unique technology for super cleanness, passivation treatment by means of special electropolishing, etc. is applied to the smooth machined surface before polishing process.

This enables to form a highly corrosion-resistant and super clean surface structure

CLEAN WELDING

Clean welding method is made available by using a high speed, full-automatic orbital welding machine. Using a sealed inner and outer manostat gauge in the clean room, inner pressure is controlled with hyper pure inert-gas so that the totally clean welding technology can fully contribute to realization of the flat bead condition, etc..

ULTRA PRECISION CLEANING

An automatic processing line including ultra pure hot water with resistivity of more than $17M\Omega$ cm has been established in the clean room.

The best possible cleaning condition is achieved here prior to the assembly.

ASSEMBLY IN THE CLEAN ROOM

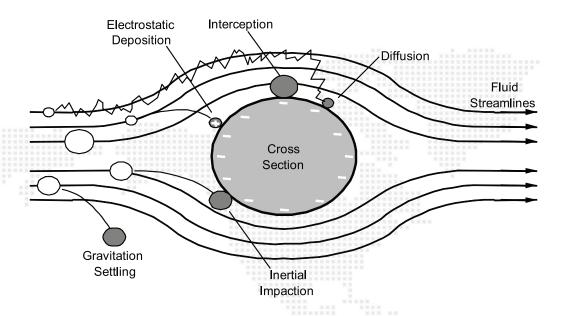
Production staffs fully acquainted with the special assembling method are dedicated to the assembly process in the certified clean room.

CLEAN PACKING

Packing is carried out at the certified clean room with inner vacuum seal method. In this way, mixing-in of foreign particles at the time of packing is extensively reduced to its minimum.



FILTRATION MECHANISM



BUSINESS SCOPE

GASES & CHEMICALS	G	A ^s	SE	S	&	Cŀ	ΗE	MI	CA	٩LS	
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PHARMACEUTICAL

FAB INSTALLATION

SEMI-CONDUCTOR & TFT-LCD

CLEAN ROOM

LAB & RESEARCH

GENERAL INDUSTRY

ENERGY AND ENVIRONMENT

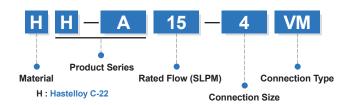
HASTELLOY GAS FILTER

HH-A SERIES

- Ultra-high purity in-line gas filter
- All Hastelloy constructions
- High temperature and dynamic pressure applications
- Compact size and variable end connections



- Wide range flow rate from 15 to 300 SLPM
- Corrosion resistant Hastelloy body with excellent performance for either inert or corrosive gas applications
- 3 Nanometer particle filtering capability keeps up high flow efficiency with minimum pressure drop
- 5Ra electro-polished surface prevents internal contaminations
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- Class 100 manufacturing, cleaning and packaging environment
- 100% helium leak tested

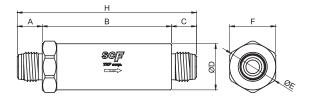


	Size	Connection		
4	1/4″	VM	MFS male type	
6	3/8″	SW	Lok type	
8	1/2″			

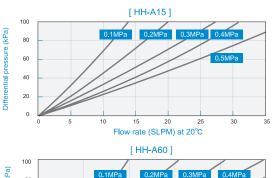
SPECIFICATIONS

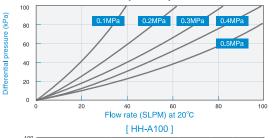
Removal Rating	≥ 0.0025µm				
Retention	Greater than 99.9999999% Removal of all particles down to 0.0025µm				
	15 SLPM				
Detect Floor	60 SLPM				
Rated Flow @ 10 ⁹	120 SLPM				
@ 10	200 SLPM				
	300 SLPM				
Materials	Filter element	Hastelloy C-276			
Waterials	Electropolished housing	Hastelloy C-22			
Onematica	Maximum inlet pressure	21 MPa (210kgf/cm²) at 20°C			
Operating Conditions	Maximum differential pressure	15 MPa (153kgf/cm²) at 20°C			
Conditions	Maximum operating temperature 460°C (Inert gas)				
Helium Leak Rating	1 x 10 ⁻⁹ atm·cc/sec				
Surface Finish Interior	≤ Ra 5µinch				

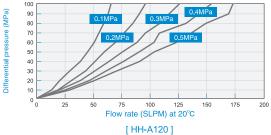
DIMENSIONS

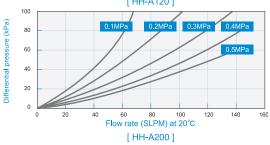


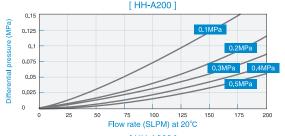
Part No.	A/mm	B/mm	C/mm	D/mm	E/mm	F/mm	H/mm
HH-A15-4VM	15.5	53	15.5	27.5	30	27	84
HH-A15-4SW	10.4	52.2	10.4	27.5	30	27	73
HH-A60-4VM	15.5	53	15.5	27.5	30	27	84
HH-A60-4SW	10.4	52.2	10.4	27.5	30	27	73
HH-A60-6(8)VM	19	53	19	27.5	30	27	91
HH-A100-8VM	19	46	19	35	39	35	84
HH-A120-4VM	15.5	96	15.5	29.5	33	30	127
HH-A120-4SW	10.4	95.2	10.4	29.5	33	30	116
HH-A120-6(8)VM	19	96	19	29.5	33	30	134
HH-A120-6(8)SW	12	96	12	29.5	33	30	120
HH-A200-4VM	15.5	98	15.5	35	39	35	129
HH-A200-4SW	10.4	97.2	10.4	35	39	35	118
HH-A200-6(8)VM	19	98	19	35	39	35	136
HH-A200-6(8)SW	12	98	12	35	39	35	122
HH-A300-4VM	15.5	98	15.5	35	39	35	129
HH-A300-4SW	10.4	97.2	10.4	35	39	35	118
HH-A300-6(8)VM	19	98	19	35	39	35	136
HH-A300-6(8)SW	12	98	12	35	39	35	122

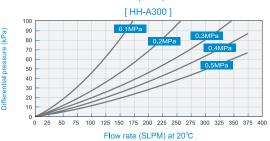












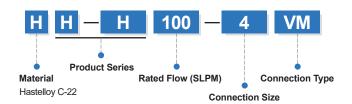
HASTELLOY GAS FILTER

HH-H SERIES

- Ultra-high purity in-line high flow gas filter
- All Hastelloy constructions
- High temperature and dynamic pressure applications
- Compact size and variable end connections



- Wide range flow rate from 100 to 800 SLPM
- Corrosion resistant Hastelloy body with excellent performance for either inert or corrosive gas applications
- 3 Nanometer particle filtering capability keeps up high flow efficiency with minimum pressure drop
- 5Ra electro-polished surface prevents internal contaminations
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- Class 100 manufacturing, cleaning and packaging environment
- 100% helium leak tested



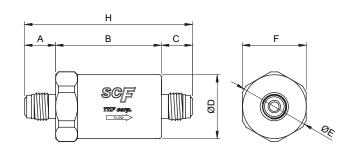
	Size	Connection		
4	1/4″	VM	MFS male type	
6	3/8″	SW	Lok type	
8	1/2"			

H: Hastelloy C-22

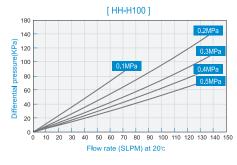
SPECIFICATIONS

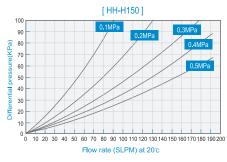
Removal Rating	≥ 0.0025µm	≥ 0.0025µm			
Retention	Greater than 99.999999% Removal of all partic	les down to 0.0025µm			
	100 SLPM (MAX 150SLPM)				
Rated Flow @ 109	150 SLPM (MAX 200SLPM)	150 SLPM (MAX 200SLPM)			
	600 SLPM (MAX 800SLPM)				
Blataviala	Filter element	Hastelloy C-276			
Materials	Electropolished housing	Hastelloy C-22			
	Maximum inlet pressure	12 MPa (122kgf/cm²) at 20°C			
Operating Conditions	Maximum differential pressure	10 MPa (101kgf/cm²) at 20°C			
	Maximum operating temperature	460°C (Inert gas)			
Helium Leak Rating	1 x 10 ⁻⁹ atm·cc/sec	1 x 10 ⁻⁹ atm·cc/sec			
Surface Finish Interior	≤ Ra 5µinch	≤ Ra 5µinch			

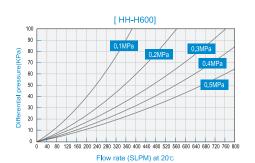
DIMENSIONS



Part No.	A/mm	B/mm	C/mm	D/mm	E/mm	F/mm	H/mm
HH-H100-4VM	15.5	53	15.5	32	35	32	84
HH-H100-4SW	10.4	52.2	10.4	32	35	32	73
HH-H100-6(8)VM	19	53	19	32	35	32	91
HH-H100-6(8)SW	12	53	12	32	35	32	77
HH-H150-4VM	15.5	53	15.5	32	35	32	84
HH-H150-4SW	10.4	52.2	10.4	32	35	32	73
HH-H150-6(8)VM	19	53	19	32	35	32	91
HH-H150-6(8)SW	12	53	12	32	35	32	77
HH-H600-6(8)VM	19	96	19	32	35	32	134
HH-H600-6(8)SW	12	96	12	32	35	32	120







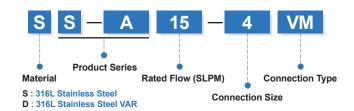
STAINLESS STEEL GAS FILTER

SS-A SERIES

- Ultra-high purity in-line gas filter
- All 316L stainless steel constructions
- High temperature and dynamic pressure applications
- Compact size and variable end connections



- Wide range flow rate from 15 to 300 SLPM
- Excellent compatibility with most high purity semiconductor process gases
- 3 Nanometer particle filtering capability keeps up high flow efficiency with minimum pressure drop
- 5Ra electro-polished surface prevents internal contaminations
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- Class 100 manufacturing, cleaning and packaging environment
- 100% helium leak tested

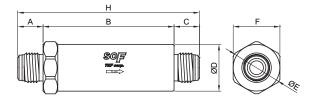


Size		Co	nnection
4	1/4″	VM	MFS male type
6	3/8″	SW	Lok type
8	1/2"		

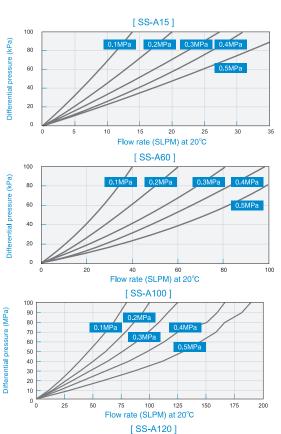
SPECIFICATIONS

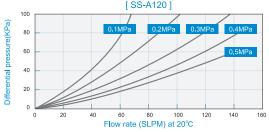
Removal Rating	≥ 0.0025µm			
Retention	Greater than 99.9999999% Removal of all particles down to 0.0025µm			
	15 SLPM			
	60 SLPM			
Rated Flow @ 109	120 SLPM			
	200 SLPM			
	300 SLPM			
	Filter element	316L Stainless steel		
Materials	Electropolished housing	316L Stainless steel 316L Stainless steel VAR		
Element	Maximum inlet pressure	21 MPa (210kgf/cm²) at 20°C		
Operating	Maximum differential pressure	15 MPa (153kgf/cm²) at 20°C		
Conditions	Maximum operating temperature	460°C (Inert gas)		
Helium Leak Rating	1 x 10 ⁻⁹ atm·cc/sec			
Surface Finish Interior	≤ Ra 5µinch			

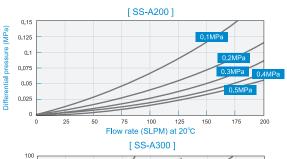
DIMENSIONS

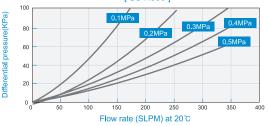


Part No.	A/mm	B/mm	C/mm	D/mm	E/mm	F/mm	H/mm
SS-A15-4VM	15.5	53	15.5	27.5	30	27	84
SS-A15-4SW	10.4	52.2	10.4	27.5	30	27	73
SS-A60-4VM	15.5	53	15.5	27.5	30	27	84
SS-A60-4SW	10.4	52.2	10.4	27.5	30	27	73
SS-A60-6(8)VM	19	53	19	27.5	30	27	91
SS-A100-8VM	19	46	19	35	39	35	84
SS-A120-4VM	15.5	96	15.5	29.5	33	30	127
SS-A120-4SW	10.4	95.2	10.4	29.5	33	30	116
SS-A120-6(8)VM	19	96	19	29.5	33	30	134
SS-A120-6(8)SW	12	96	12	29.5	33	30	120
SS-A200-4VM	15.5	98	15.5	35	39	35	129
SS-A200-4SW	10.4	97.2	10.4	35	39	35	118
SS-A200-6(8)VM	19	98	19	35	39	35	136
SS-A200-6(8)SW	12	98	12	35	39	35	122
SS-A300-4VM	15.5	98	15.5	35	39	35	129
SS-A300-4SW	10.4	97.2	10.4	35	39	35	118
SS-A300-6(8)VM	19	98	19	35	39	35	136
SS-A300-6(8)SW	12	98	12	35	39	35	122









STAINLESS STEEL GAS FILTER

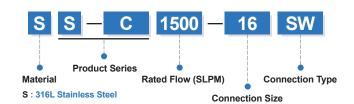
SS-C SERIES

- Ultra-high purity inline Gas filter
- All 316L Stainless steel constructions
- High temperature and dynamic pressure applications





- For high flow applications
- Excellent compatibility with most high purity semiconductor process gases
- 3 Nanometer particle filtering capability keeps up high flow efficeincy with minimum pressure drop
- 5Ra electro-polished surface prevents internal contaminations
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- 100%helium leak tested



	Size	Co	nnection
12	3/4"	VM	MFS male type
16	1"	SW	Lok type

SPECIFICATIONS

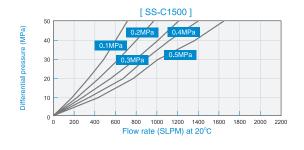
Max. Inlet Pressi	ure	0.98MPa(10kg/cm²) @ 20°C		
Removal Rating		≥ 0.0025 µinch		
Particle Retention	on	99.999999% Removal of all particles down to 0.0025 μinch		
T	(Electric)	Less than 460°C		
Temperature Ra	nge (Fiula)	Less than 460°C		
	11	316L Stainless steel		
BELLEVIOLE	Housing	316L Stainless steel		
Materials		Test pressure≤1x10² Torr Holding time ≥ 1min.		
Element		≤1x10 ⁹ atm·cc/sec		
1 1	External Leakage	Test pressure≤1x10² Torr Holding time ≥ 1min.		
Leakage	Allowance (He)	≤1x10 ⁹ atm·cc/sec		
Nominal DIA.		1"		
Flow Rate		1500 SLPM		
Connection Met	hod	Lok		
Grade		EP		
Products Inner Surface Squade Roughness Ry ≤ 0.7μinch 5μ Inch Ra (Avg.) Cut off Length : 0.25mm Measuring Length : 1.25mm		$5 \mathring{\mu}$ Inch Ra (Avg.) Cut off Length : 0.25mm		
	Electropolishing	Electro Polishing Finish		

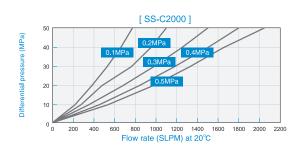
DIMENSIONS





Part No.	A/mm	B/mm	C/mm	D/mm	F/mm	H/mm
SS-C1500-12VM	25.5	176	25.5	76.3	36	227
SS-C1500-16SW	19.0	172	19.0	76.3	41	210
SS-C2000-16SW	19.0	172	19.0	76.3	41	210





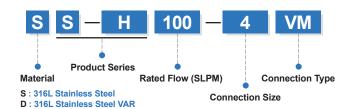
STAINLESS STEEL GAS FILTER

SS-H SERIES

- Ultra-high purity in-line high flow gas filter
- All 316L stainless steel constructions



- Wide range flow rate from 100 to 800 SLPM
- Excellent compatibility with most high purity semiconductor process gases
- 3 Nanometer particle filtering capability keeps up high flow efficiency with minimum pressure drop
- 5Ra electro-polished surface prevents internal contaminations
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- Class 100 manufacturing, cleaning and packaging environment
- 100% helium leak tested

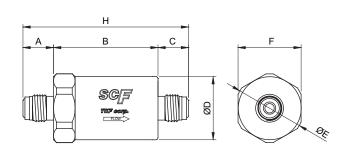


	Size	Co	nnection
4	1/4″	VM	MFS male type
6	3/8″	SW	Lok type
8	1/2″		

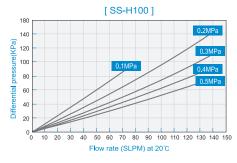
SPECIFICATIONS

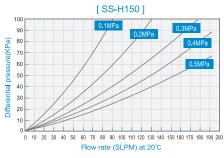
Removal Rating	≥ 0.0025µm			
Retention	Greater than 99.9999999% Removal of all particles down to 0.	0025μm		
	100 SLPM (MAX 150SLPM)			
Rated Flow @ 10°	150 SLPM (MAX 200SLPM)			
	600 SLPM (MAX 800SLPM)			
Makawiala	Filter element	316L Stainless steel		
Materials	Electropolished housing	316L Stainless steel / 316L Stainless steel VAR		
	Maximum inlet pressure	12 MPa (122kgf/cm²) at 20°C		
Operating Conditions	Maximum differential pressure	10 MPa (101kgf/cm²) at 20°C		
	Maximum operating temperature	460°C (Inert gas)		
Helium Leak Rating	1 x 10 ⁻⁹ atm·cc/sec			
Surface Finish Interior	≤ Ra 5µinch			

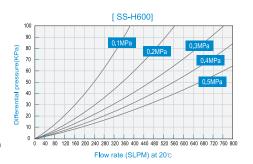
DIMENSIONS



Part No.	A/mm	B/mm	C/mm	D/mm	E/mm	F/mm	H/mm
SS-H100-4VM	15.5	53	15.5	32	35	32	84
SS-H100-4SW	10.4	52.2	10.4	32	35	32	73
SS-H100-6(8)VM	19	53	19	32	35	32	91
SS-H100-6(8)SW	12	53	12	32	35	32	77
SS-H150-4VM	15.5	53	15.5	32	35	32	84
SS-H150-4SW	10.4	52.2	10.4	32	35	32	73
SS-H150-6(8)VM	19	53	19	32	35	32	91
SS-H150-6(8)SW	12	53	12	32	35	32	77
SS-H600-4VM	15.5	96	15.5	32	35	32	127
SS-H600-4SW	10.4	95.2	10.4	32	35	32	116
SS-H600-6(8)VM	19	96	19	32	35	32	134
SS-H600-6(8)SW	12	96	12	32	35	32	120







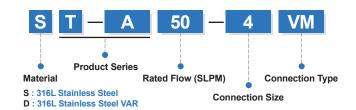
PTFE GAS FILTER

ST-A SERIES

- Ultra-high purity in-line gas filter
- All fluoropolymer filter element
- Electropolished 316L stainless steel housing



- PTFE element with superior corrosion resistance and excellent compatibility for most high purity semiconductor process gases
- 3 Nanometer particle filtering capability keeps up high flow efficiency with minimum pressure drop
- 5Ra electro-polished surface prevents internal contaminations
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- Class 100 manufacturing, cleaning and packaging environment
- 100% helium leak tested

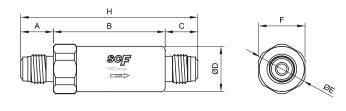


	Size	Co	nnection
4	1/4″	VM	MFS male type
6	3/8″	SW	Lok type
8	1/2″		

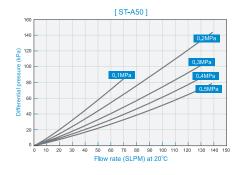
SPECIFICATIONS

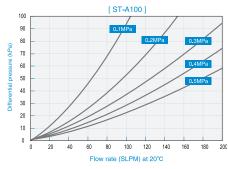
Removal Rating	≥ 0.0025µm	≥ 0.0025µm		
Retention	Greater than 99.999999% Removal of all partic	Greater than 99.999999% Removal of all particles down to 0.0025µm		
	50 SLPM	50 SLPM		
Rated Flow @ 109	100 SLPM			
	150 SLPM			
Metaviala	Filter element / Support / O-ring	PTFE / PFA / PTFE		
Materials	Electropolished housing	316L Stainless steel / 316L Stainless steel VAR		
	Maximum inlet pressure	0.98 MPa (10kgf/cm²) at 20°C		
Operating Conditions	Maximum differential pressure	0.4 MPa (4.2kgf/cm²) at 20°C		
	Maximum operating temperature	120°C (Inert gas)		
Helium Leak Rating	1 x 10 ⁻⁹ atm·cc/sec			
Surface Finish Interior	≤ Ra 5µinch			

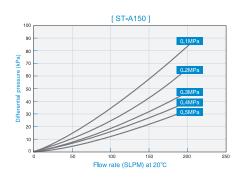
DIMENSIONS



Part No.	A/mm	B/mm	C/mm	D/mm	E/mm	F/mm	H/mm
ST-A50-4VM	15.5	53	15.5	21.5	23.5	22	84
ST-A50-4SW	10.4	52.2	10.4	21.5	23.5	22	73
ST-A100-4VM	15.5	96	15.5	26.5	30	27	127
ST-A100-4SW	10.4	95.2	10.4	26.5	30	27	116
ST-A100-6(8)VM	19	96	19	26.5	30	27	134
ST-A100-6(8)SW	12	96	12	26.5	30	27	120
ST-A150-4VM	15.5	96	15.5	26.5	30	27	127
ST-A150-4SW	10.4	95.2	10.4	26.5	30	27	116
ST-A150-6(8)VM	19	96	19	26.5	30	27	134
ST-A150-6(8)SW	12	96	12	26.5	30	27	120







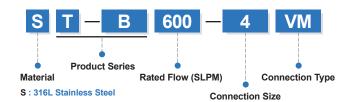
PTFE GAS FILTER

ST-B SERIES

- Ultra-high purity in-line gas filter
- All fluoropolymer filter element
- Electropolished 316L stainless steel housing



- PTFE element with superior corrosion resistance and excellent compatibility for most high purity semiconductor process gases
- 3 Nanometer particle filtering capability keeps up high flow efficiency with minimum pressure drop
- 5Ra electro-polished surface prevents internal contaminations
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- Class 100 manufacturing, cleaning and packaging environment
- 100% helium leak tested

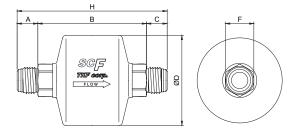


	Size	Co	nnection
4	1/4″	VM	MFS male type
6	3/8″	SW	Lok type
8	1/2"		

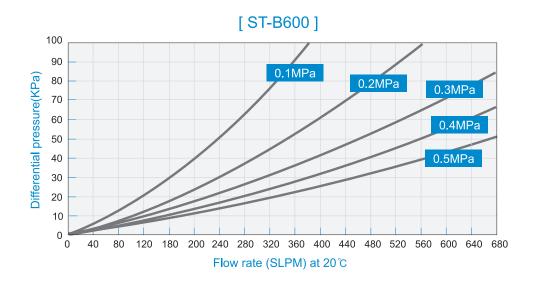
SPECIFICATIONS

Removal Rating	≥ 0.0025µm			
Retention	Greater than 99.9999999% Removal of all particles down to 0.	.0025μm		
Rated Flow @ 10°	600 SLPM (MAX 1000SLPM)			
Materials	Filter element / Support / O-ring PTFE / PFA / FKM			
Waterials	Electropolished housing	316L Stainless steel / 316L Stainless steel VAR		
	Maximum inlet pressure	0.98 MPa (10kgf/cm²) at 20°C		
Operating Conditions	Maximum differential pressure	0.4 MPa (4.2kgf/cm²) at 20°C		
	Maximum operating temperature 120°C (Inert gas)			
Helium Leak Rating	1 x 10 ⁹ atm·cc/sec			
Surface Finish Interior	≤ Ra 5µinch	≤ Ra 5µinch		

DIMENSIONS



Part No.	A/mm	B/mm	C/mm	D/mm	F/mm	H/mm
ST-B600-4VM	15.5	96	15.5	76.3	24	127
ST-B600-4SW	10.4	92.2	10.4	76.3	24	113
ST-B600-6(8)VM	19	89	19	76.3	24	127
ST-B600-6(8)SW	12	89	19	76.3	24	113
ST-B600-12VM	25.5	82	25.5	76.3	36	133
ST-B600-12SW	17	82	17	76.3	36	116



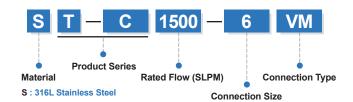
PTFE GAS FILTER

ST-C SERIES

- Ultra-high purity in-line gas filter
- All fluoropolymer filter element
- Electropolished 316L stainless steel housing



- PTFE element with superior corrosion resistance and excellent compatibility for most high purity semiconductor process gases
- 3 Nanometer particle filtering capability keeps up high flow efficiency with minimum pressure drop
- 5Ra electro-polished surface prevents internal contaminations
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- Class 100 manufacturing, cleaning and packaging environment
- 100% helium leak tested

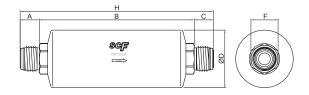


	Size	Connection		
6	3/8″	VM MFS male type		
8	1/2"	SW	Lok type	
		А	Tube size	
		TW Butt Weld type		

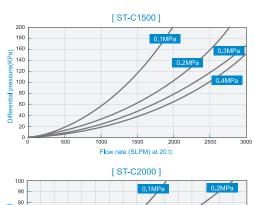
SPECIFICATIONS

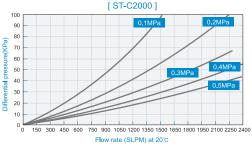
Removal Rating	≥ 0.0025µm	≥ 0.0025µm		
Retention	Greater than 99.999999% Removal of all particles down	to 0.0025µm		
Rated Flow @ 10°	1500 SLPM, 2000 SLPM, 2500 SLPM, 3500 SLPM, 750	500 SLPM, 2000 SLPM, 2500 SLPM, 3500 SLPM, 7500 SLPM		
Materials	Filter element / Support / O-ring	PTFE / PP / FKM		
Waterials	Electropolished housing	316L Stainless steel / 316L Stainless steel VAR		
	Maximum inlet pressure	0.98 MPa (10kgf/cm²) at 20°C		
Operating Conditions	Maximum differential pressure	0.4 MPa (4.2kgf/cm²) at 20°C		
	Maximum operating temperature	100°C (Inert gas)		
Helium Leak Rating	1 x 10 ⁻⁹ atm·cc/sec			
Surface Finish Interior	≤ Ra 5µinch			

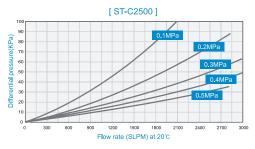
DIMENSIONS

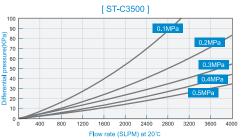


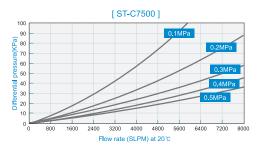
Part No.	A/mm	B/mm	C/mm	D/mm	F/mm	H/mm
ST-C1500-6(8)VM	19	198	19	76.3	24	236
ST-C1500-8SW	12	198	12	76.3	24	223
ST-C1500-12VM	25.5	205.6	25.5	76.3	36	256.6
ST-C1500-12SW	17	205.6	17	76.3	36	239.6
ST-C1500-8TW	56.2	183	56.2	76	-	295
ST-C1500-15A	48.5	184	48.5	76.6	-	281
ST-C2000-15A	48.5	184	48.5	76.2	-	281
ST-C2500-20A	70	303.5	70	89.1	-	443.5
ST-C3500-25A	70	310	70	89.1	-	450
ST-C7500-40A	70	551	70	89.1	-	691











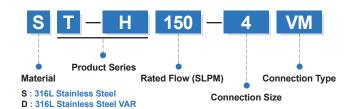
PTFE GAS FILTER

ST-H MAX SERIES

- Ultra-high purity max in-line gas filter
- All fluoropolymer filter element
- Electropolished 316L stainless steel housing



- PTFE element with superior corrosion resistance and excellent compatibility for most high purity semiconductor process gases
- 3 Nanometer particle filtering capability keeps up high flow efficiency with Low pressure drop
- 5Ra electro-polished surface prevents internal contaminations
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- Class 100 manufacturing, cleaning and packaging environment
- 100% helium leak tested

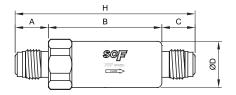


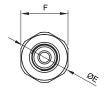
	Size	Co	nnection
4	1/4″	VM	MFS male type
6	3/8″	SW	Lok type
8	1/2″		

SPECIFICATIONS

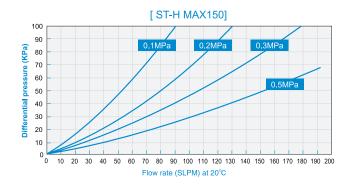
Removal Rating	≥ 0.0025µm	≥ 0.0025μm		
Retention	Greater than 99.999999% Removal of all partic	Greater than 99.999999% Removal of all particles down to 0.0025µm		
Data d Flance 240°	150 SLPM (Max 200 SLPM)			
Rated Flow @ 10°	300 SLPM (Max 400 SLPM)			
Materials	Filter element / Support / O-ring	PTFE / PFA / PTFE		
	Electropolished housing	316L Stainless steel / 316L Stainless steel VAR		
	Maximum inlet pressure	0.98 MPa (10kgf/cm²) at 20°C		
Operating Conditions	Maximum differential pressure	0.4 MPa (4.2kgf/cm²) at 20°C		
	Maximum operating temperature	120°C (Inert gas)		
Helium Leak Rating	1 x 10 ⁻⁹ atm·cc/sec			
Surface Finish Interior	≤ Ra 5µinch			

DIMENSIONS





Part No.	A/mm	B/mm	C/mm	D/mm	E/mm	F/mm	H/mm
ST-H150-4VM	15.5	53	15.5	21.5	23.5	22	84
ST-H150-4SW	10.4	52.2	10.4	21.5	23.5	22	73
ST-H300-6(8)VM	19	96	19	26.5	30	27	134
ST-H300-6(8)SW	12	96	12	26.5	30	27	120





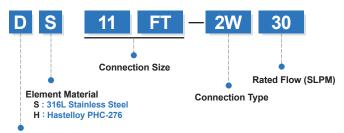
IGS GAS FILTER

METAL SERIES

- Ultra-high purity Metal Mini gas filter
- All 316L stainless steel constructions
- High temperature and dynamic pressure applications
- Compact size and high reliability on shock or vibration



- Wide range flow rate from 30 to 120 SLPM
- Excellent compatibility with most high purity semiconductor process gases
- 3 Nanometer particle filtering capability keeps up high flow efficiency with minimum pressure drop
- 5Ra electro-polished surface prevents internal contaminations
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- Class 100 manufacturing, cleaning and packaging environment
- 100% helium leak tested



	Size	Co	nnection
11	1.125″	W, WS	W-Seal
15	1.5″	С	C-Seal
159	1.59"		

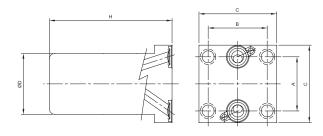
Housing Material

S : 316L Stainless Steel D : 316L Stainless Steel VAR H : Hastelloy C-22

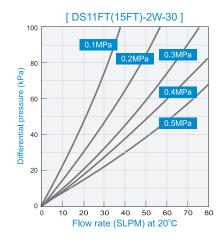
SPECIFICATIONS

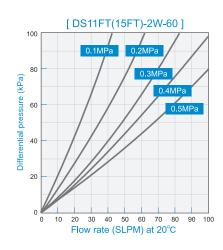
Removal Rating	≥ 0.0025µm			
Retention	Greater than 99.999999% Removal of all particles down to 0.0025µm			
	30 SLPM			
Rated Flow @ 109	60 SLPM			
	120 SLPM			
Materials	Filter element	316L Stainless steel, Hastelloy C276		
	Electropolished housing 316L Stainless steel / 316L Stainless steel loy C22			
	Maximum inlet pressure	0.98 MPa (10kgf/cm²) at 20°C		
Operating Conditions	Maximum differential pressure	0.7 MPa (7kgf/cm²) at 20°C		
	Maximum operating temperature 460°C (Inert gas)			
Helium Leak Rating	1 x 10 ⁻⁹ atm·cc/sec			
Surface Finish Interior	≤ Ra 5µinch			

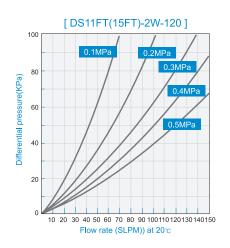
DIMENSIONS



Size	Sear Type	Part Number	A/mm	B/mm	C/mm	mm/ט	H/mm
		DS11FT-2W-30	20	21.8	28.6	21.5	45.5
	W-Seal	DS11FT-2W-60	20	21.8	28.6	21.5	58.5
1.125″		DS11FT-2W-120	20	21.8	28.6	27.5	109
1.125		DS11FT-2C-30	21.8	21.8	28.6	21.5	45.5
	C-Seal	DS11FT-2C-60	21.8	21.8	28.6	21.5	58.5
		DS11FT-2C-120	21.8	21.8	28.6	21.5	58.5
	W-Seal	DS15FT-2W-30	26	30	39	27.5	51
1.5″		DS15FT-2W-60	26	30	39	27.5	62
		DS15FT-2W-120	26	30	39	27.5	97.5
1.5		DH15FT-2W-120	26	30	39	27.5	97.5
	C-Seal	DS15FT-2C-30	30.2	30.2	39	27.5	62
	C-Seal	DS15FT-2C-60	30.2	30.2	39	27.5	97.5
1.59"	W-Seal	DH159FT-2WS-120	18	42	37 x 55	27.5	97.5







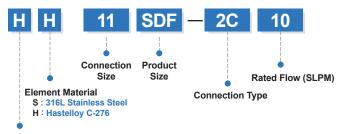
1.125" SANDWICH GAS FILTER

SDF SERIES

- Ultra-high purity IGS gas filter
- All 316L stainless steel or Hastelloy construction
- High temperature and dynamic pressure applications



- Excellent compatibility with most high purity semiconductor process gases
- 3 Nanometer particle filtering capability keeps up high flow efficiency with minimum pressure drop
- 5Ra electro-polished surface prevents internal contaminations
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- 100%helium leak tested
- 1.125" C-Seal Surface Mount Sandwich filter design provides a feedthrough for incoming gas to the device mounted above.
- Gas filtration is provided as the gas is returning from the above mounted device to allow for the maximum protection for any downstream components.



Connection 1.125" C-Seal

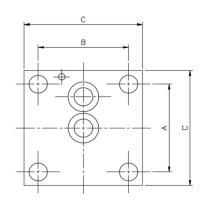
Housing Material
D: 316L Stainless Steel VAR
H: Hastelloy C-22

SPECIFICATIONS

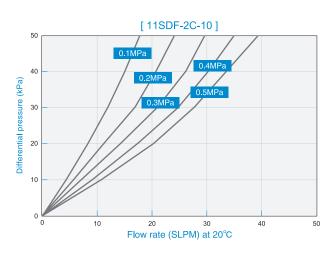
Removal Rating	≥ 0.0025µm				
Retention	Greater than 99.999999% Removal of all particle	Greater than 99.999999% Removal of all particles down to 0.0025µm			
Botad Flow @ 409	10 SLPM				
Rated Flow @ 10 ⁹	30 SLPM	30 SLPM			
Materials	Filter element	316L Stainless Steel / Hastelloy C-276			
Materials	Housing	316L VAR Stainless Steel / Hastelloy C-22			
	Maximum inlet pressure	5 MPa (50.98kgf/cm²) at 20°C			
Element operating conditions	Maximum differential pressure	0.7 MPa (7kgf/cm²) at 20°C			
	Maximum operating temperature	460°C			
Helium Leak Rating	1 x 10 ⁻⁹ atm·cc/sec				
Surface Finish Interior	≤ Ra 5µinch				

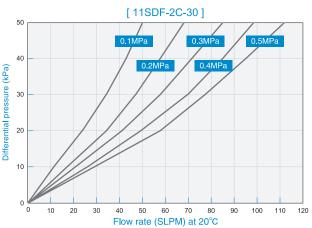
DIMENSIONS





Series	Size	Part Number	A/mm	B/mm	C/mm	D/mm
11SDF	1.125" C-Seal Type	DS11SDF-2C-10	21.8	21.8	28.5	15.2
11SDF	1.125" C-Seal Type	DS11SDF-2C-30	21.8	21.8	28.5	22.9
11SDF	1.125" C-Seal Type	HH11SDF-2C-10	21.8	21.8	28.5	15.2
11SDF	1.125" C-Seal Type	HH11SDF-2C-30	21.8	21.8	28.5	22.9





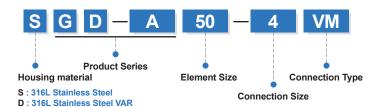
GAS DIFFUSER

METAL SERIES

- Ultra-high purity Metal Gas Diffuser
- 316L Stainless steel element
- High temperature applications
- Compact size and high reliability on shock or vibration



- Wide range flow rate from 60 to 300 SLPM
- Excellent compatibility with most high purity semiconductor process gases
- 3 Nanometer particle filtering capability keeps up high flow efficiency with minimum pressure drop
- 5Ra electro-polished surface prevents internal contaminations
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- 100%helium leak tested

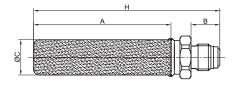


Size		Connection		
4	1/4″	VM	MFS male type	
6	3/8″	NW25X8VM	NW25 flange type	
8	1/2″			

SPECIFICATIONS

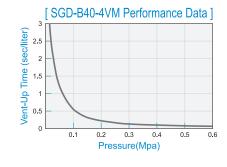
Removal Rating		≥ 0.0025µm		
Retention		Greater than 99.999999% Removal of all particles down to 0.0025µm		
Rated Flow @ 10°		70SLPM (A50)		
		60SLPM (B40)		
		80SLPM (B70)		
		90SLPM (B74)		
		300SLPM (C80)		
		100SLPM (NW25X8VM)		
Materials	Filter Element	316L Stainless Steel		
Materials	Housing	316L Stainless Steel / 316L VAR Stainless Steel		
Element Operating Conditions	Maximum inlet pressure	1Мра		
Element Operating Conditions	Maximum Operating Temperature	460°C		
Surface Finish Interior		≤ Ra 10µin(BA) / ≤ Ra 5µin(EP)		

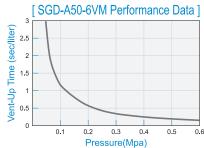
DIMENSIONS

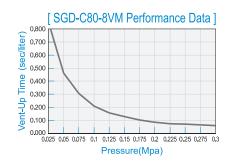


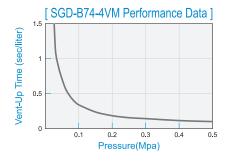


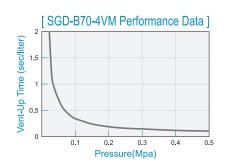
Series	Size	Part Number	A/mm	B/mm	C/mm	D/mm	E/mm	H/mm
SGD-A	3/8"	GD-A50-6VM	50	19	13	27	24	81.5
SGD-B	1/4″	GD-B40-4VM	40	15.5	19	23	21	66.3
		GD-B70-4VM	70	15.5	19	23	21	96.3
		GD-B74-4VM	74	15.5	19	23	21	100.3
	1/2"	GD-B74-NW25X8VM	74	39.4	19	40	23.8	123.4
SGD-C	1/2"	GD-C80-8VM	80	19	24	27	24	110.8

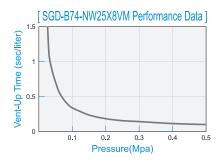










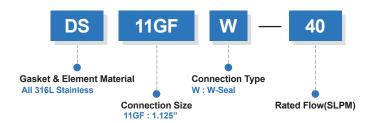


GASKET FILTER

IGS SERIES



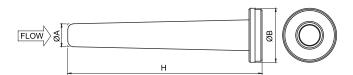
- 3 Nanometer particle filtering capability keeps up high flow efficiency with minimum pressure drop
- Gasket surface finish on gas wetted surface is 5µm in Ra with electro polishing
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- Class 100 manufacturing, cleaning and packaging environment



SPECIFICATIONS

Removal Rating	≥ 0.0025µm
Retention	Greater than 99.999999% Removal of all particles down to 0.0025µm
Rated Flow @ 10°	40 SLPM
Max. Operating Temperature	460°C
Surface Finish Interior	≥ Ra 5µinch

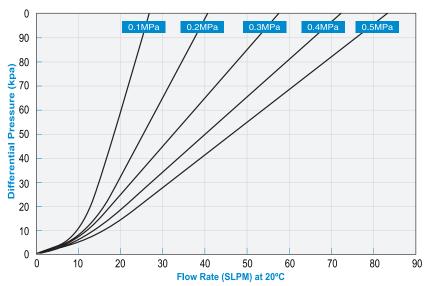
DIMENSIONS



Size	Seal Type	Part Number	A/mm	B/mm	H/mm
1.125″	W-Seal	DS11GFW-40	(3.25)	7.7	27.6

PERFORMANCE DATA

GASKET FILTER FLOW CURVE

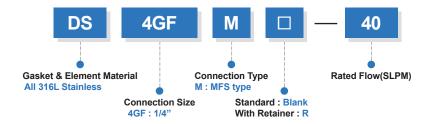


GASKET FILTER

MFS SERIES



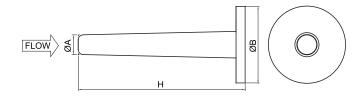
- 3 Nanometer particle filtering capability keeps up high flow efficiency with minimum pressure drop
- Gasket surface finish on gas wetted surface is 5µm in Ra with electro polishing
- Baked with hot nitrogen after DI water cleaning to meet semiconductor process standards
- Class 100 manufacturing, cleaning and packaging environment

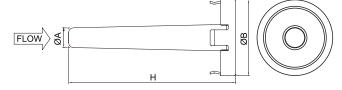


SPECIFICATIONS

Removal Rating	≥ 0.0025µm
Retention	Greater than 99.999999% Removal of all particles down to 0.0025µm
Rated Flow @ 10 ⁹	40 SLPM
Max. Operating Temperature	460°C
Surface Finish Interior	≥ Ra 5µinch

DIMENSIONS





Size	Seal Type	Part Number	A/mm	B/mm	H/mm
1/4″	MFS Type	D4GFM-40	(3.25)	12.7	27.6

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PERFORMANCE DATA

GASKET FILTER FLOW CURVE

